

**In the Claims:**

1. (Canceled)

2. (Canceled)

3. (Canceled)

4. (Canceled)

5. (Amended) A board for a plasma color display[, ] on which striped barrier ribs for partitioning address electrodes and discharge spaces are formed[, ] and on which phosphor layer stripes emitting [light of] red, green and blue light are formed in [the] grooves between the respectively adjacent barrier ribs, [characterized in that] wherein two or more phosphor layer stripes [respectively] emitting light of the same color are formed in respectively adjacent [two or more] grooves.

6. (Amended) A board for a plasma display[, ] according to claim 5, wherein [the] two or more blue light emitting phosphor layer stripes are formed in the respectively adjacent [two or more] grooves.

7. (Amended) A plasma display, [which is composed of] comprising a front glass board having electrodes, a dielectric and a protective film formed on [it] the front glass board and a rear glass board having electrodes, a dielectric, barrier ribs and phosphors formed on [it] the rear glass board, [characterized in that] the board for a plasma display [stated in] according to [any one of claims 1 through 6 is] claim 5 being used as the rear board.

8. (Amended) A process for producing the board for a plasma display [stated in] according to [any one of claims 1 through 6] claim 5, comprising, [the step of fully] in order, applying a photosensitive paste over a surface of the board, [the step of] exposing the photosensitive paste to a barrier rib pattern, [the step of] developing the exposed photosensitive paste of the board [for removing the] to remove portions dissolved by a developer, and [the step of] firing the developed board at 450°C to 620°C [in this order], [as a means for forming the] so as to form barrier ribs on the board.

9. (New) A plasma display, comprising a front glass board having electrodes, a dielectric and a protective film formed on the front glass board and a rear glass board having electrodes, a dielectric, barrier ribs and phosphors formed on the rear glass board, the board for a plasma display according to claim 6 being used as the rear board.

10. (New) A process for producing the board for a plasma display according to claim 6, comprising, in order, applying a photosensitive paste over a surface of the board, exposing the photosensitive paste to a barrier rib pattern, developing the exposed photosensitive paste of the board to remove portions dissolved by a developer, and firing the developed board at 450°C to 620°C, so as to form barrier ribs on the board.